



Application No. 10/697,053  
Attorney Docket No. SEC.1049  
Amendment Filed September 1, 2005

*IN THE UNITED STATES PATENT AND TRADEMARK OFFICE*

In re PATENT APPLICATION of : Allowed: June 2, 2005  
Jin-Sung Kim et al. : Group Art Unit: 2823  
Application No.: 10/697,053 : Examiner: Pham, Thanh V.  
Filed: October 31, 2003 :

METHOD OF FORMING A POROUS MATERIAL LAYER IN A SEMICONDUCTOR  
DEVICE

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**AMENDMENT AFTER ALLOWANCE**

U.S. Patent and Trademark Office  
**Customer Service Window, Mail Stop Issue Fee**  
Randolph Building  
401 Dulany Street  
Alexandria VA 22314

Sir:

Subsequent to the issuance of a Notice of Allowance dated June 2, 2005,  
and prior to the payment of the issue fee, please amend the above-identified  
application as follows:

**Amendments to the Claims** are reflected in the listing of claims which  
begins on page 2 of this paper.

**Remarks/Arguments** begin on page 5 of this paper.